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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 3698**  
Jyun IWASHITA et al. : Attorney Docket No. 2005\_1513A  
Serial No. 10/549,849 : Group Art Unit 1795  
Filed December 12, 2005 : Examiner Ponder N. Thompson Rummel  
NEGATIVE RESIST COMPOSITION AND : **Mail Stop: AMENDMENT**  
METHOD OF FORMING RESIST PATTERN

**RESPONSE**

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEES FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO 23-0975

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated October 26, 2007, please amend the present application as follows: